Listing of the Claims

- 1. (Currently Amended) A system for magnetic resonance imaging, comprising:
- a substantially cylindrical cavity (2);
- wherein the cavity (2) has an axis of symmetry in the direction of a z-axis;
- wherein a subject (3) can be examined within the cavity;
- wherein the subject (3) has a conductance which is not isotropic in an xyplane which is perpendicular to the z-axis;

characterized in that wherein an electrically conductive material (4)-is placed within the cavity-(2), wherein the material (4)-has a conductivity and a thickness which render the total conductance in the xy-plane within the cavity to be isotropic.

- 2. (Currently Amended) A system according to claim 1, characterized in that wherein the system is a magnetic resonance imaging apparatus or a radio frequency (RF) coil for magnetic resonance imaging.
- 3. (Currently Amended) A system according to claim 2, eharacterized in that wherein at least a part of the material (4)-is attached to an inner wall (5) of the cylindrical cavity-(2).
- 4. (Currently Amended) A system according to claim 1, characterized in that wherein at least a part of the material (4)-is attached to a bottom (6) of a substantially plane surface (7)-on which the subject (3) can be positioned.
- 5. (Currently Amended) A system according to claim 4, characterized in that wherein the substantially plane surface (7) is part of a patient's bed.
- 6. (Currently Amended) A system according to claim 3, 4 or 5, eharacterized in that wherein the electrically conductive material (4) is removably attached within the cavity (2).

- 7. (Currently Amended) A system according to claim 1, eharacterized in that wherein the material (4)-is substantially above and below a substantially plane surface (7) on which the subject (3)-can be positioned.
- 8. (Currently Amended) A system according to claim 1, characterized in that wherein the material (4) has a planar resistance between about 5 Ω and about 20 Ω .
- 9. (Currently Amended) A system according to claim 7, characterized in that wherein the material above the subject (3)-has a planar resistance between about 5 Ω and about 10 Ω .
- 10. (Currently Amended) A system according to claim 7, characterized in that wherein the material below the subject (3) has a planar resistance between about 12 Ω and about 16 Ω .
- 11. (Currently Amended) A system according to claim 1, characterized in that wherein the material (4) is a sheet (8) being covered by a conductive layer (9).
- 12. (Currently Amended) A system according to claim 11, characterized in that wherein only predetermined parts of the sheet (8) are covered by a conductive layer (9).
- 13. (Currently Amended) A system according to claim 1, characterized in that wherein it is arranged to operate with magnetic fields at or above 3 tesla.